

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

cant(s): Jack A. Mandelman, et al.

Examiner: David S. Blum

Serial No: 10/004,152

Art Unit: 2813

Filed: October 24, 2001

Docket: FIS920010265US1 (14912)

For: METHOD FOR MULTI-

**DEPTH TRENCH ISOLATION** 

Dated: February 4, 2003

TECHNOLOGY CERTER 2800

FEB | 4 2003

Assistant Commissioner for Patents Washington, D.C. 20231

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## **AMENDMENT AND RESPONSE**

Sir:

In response to the Office Action dated November 4, 2002, applicants have filed, herewith, a Request for a Continued Examination (RCE) application. Additionally, applicants submit the following amendments and remarks for entry of record in the RCE application.

## IN THE CLAIMS:

Please amend Claims 1 and 12 to read as follows:

BI

1. (Twice Amended) A method for forming multi-depth apertures in a

## **CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Assistant Commissioner of Patents and Trademarks, Washington, D.C. 20231 on February 4, 2003

Dated: February 4, 2003

Mishelle Mustafa